

EAST Search History

EAST Search History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S28	2	"20070105997".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2010/04/01 16:50
S29	28	("20050118595" "20050118595" "20050276835" "5776748" "5858188" "5869135" "5935409" "6074725" "6086679" "6103479" "6192168" "6291072" "6712846" "6977138" "6977138").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2010/04/07 14:30
S30	8	(lahann or elkasabi).in. and paracyclophane and (CVD or chemical vapor deposition or pyrolysis) and copolymer\$5	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2010/04/07 14:45
S31	11	paracyclophane same copolymer\$5 and (CVD or chemical vapor deposition or pyrolysis)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2010/04/07 14:49
S32	4	mix\$3 with paracyclophane and (CVD or chemical vapor deposition or pyrolysis)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2010/04/07 15:20
S33	9	maruyama.in. and paracyclophane and (CVD or chemical vapor deposition or pyrolysis)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2010/04/07 15:25

S34	133	paracyclophane and (CVD or chemical vapor deposition or pyrolysis)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2010/04/07 15:29
S35	2	copolymeriz\$5 with xylylene and paracyclophane	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2010/04/07 15:33
S36	1	co-polymeriz\$5 with xylylene and paracyclophane	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2010/04/07 15:33
S37	24	(co-polymer\$5 or copolymer\$5) with (xylylene or PPX or para-xylylene) and paracyclophane	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2010/04/07 15:34
S38	4	paracyclophane with mix\$3 same (CVD or chemical vapor deposition)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2010/04/07 15:35
S39	4	paracyclophane with mix\$3 same3 (CVD or chemical vapor deposition)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2010/04/07 15:36
S40	56	paracyclophane same3 (CVD or chemical vapor deposition)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2010/04/07 15:36
S41	4	("3375419" "5393533" "6123993").PN. OR ("6855419").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/04/07 15:36
S43	77	polymeriz\$5 and paracyclophane and (CVD or chemical vapor deposition)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2010/04/07 15:38
S44	2	"6323297".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2010/04/07 15:54

S45	8	("6323297").URPN.	USPAT	ADJ	ON	2010/04/07 15:59
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EAST Search History (Interference)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S46	1	427/255.28.ccls. and (paracyclophane or p-xylylene or paraxylylene of PPX).clm.	USPAT; UPAD	ADJ	ON	2010/04/07 18:13
S47	318	(paracyclophane or p-xylylene or paraxylylene of PPX).clm.	USPAT; UPAD	ADJ	ON	2010/04/07 18:15
S48	7	S47 and (CVD or chemical vapor deposit \$3).clm.	USPAT; UPAD	ADJ	ON	2010/04/07 18:15
S49	5	polyparaxylylene.clm. and (CVD or chemical vapor deposit\$3).clm.	USPAT; UPAD	ADJ	ON	2010/04/07 18:16
S50	1	paracyclophane.clm. and (CVD or chemical vapor deposit\$3).clm.	USPAT; UPAD	ADJ	ON	2010/04/07 18:22
S51	4	polymerization.clm. and (CVD or chemical vapor deposit\$3).clm. and paracyclophane	USPAT; UPAD	ADJ	ON	2010/04/07 18:22
S52	26	polyparaxylylene.clm. and (CVD or chemical vapor deposit\$)	USPAT; UPAD	ADJ	ON	2010/04/07 18:23
S53	58	polyparaxylylene.clm.	USPAT; UPAD	ADJ	ON	2010/04/07 18:24
S54	2	polyparaxylylene and (CVD or chemical vapor deposition) and paracyclophane	USPAT; UPAD	ADJ	ON	2010/04/07 18:25
S55	4	mix\$3 with paracyclophane	USPAT; UPAD	ADJ	ON	2010/04/07 18:27

4/7/2010 7:42:08 PM

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 \10596589.CVD.polyparaxylylene.wsp**